

## Supporting Information

### Ultralow-Threshold Up-Converted Lasing in Oligofluorenes with Tailored Strong Nonlinear Absorption

Burak Guzelturk<sup>1,#</sup>, Alexander L. Kanibolotsky<sup>2,3,#</sup>, Clara Orofino-Pena<sup>2</sup>, Nicolas Laurand<sup>4</sup>, Martin D. Dawson<sup>4</sup>, Peter J. Skabara<sup>2,\*</sup>, and Hilmi Volkan Demir<sup>1,5,\*</sup>

<sup>1</sup> Department of Electrical and Electronics Engineering, Department of Physics, UNAM - Institute of Materials Science and Nanotechnology, Bilkent University, Ankara 06800 Turkey

<sup>2</sup> WestCHEM, Department of Pure and Applied Chemistry, University of Strathclyde, Thomas Graham Building, 295 Cathedral Street, Glasgow G1 1XL, UK

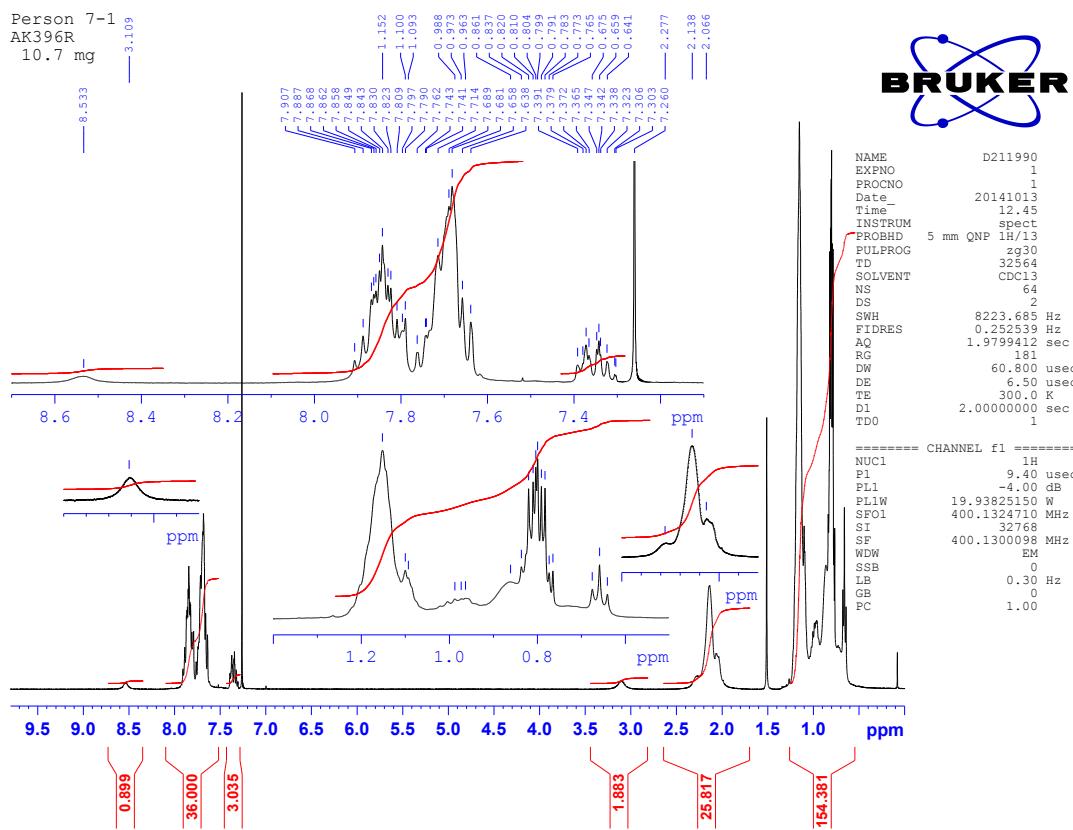
<sup>3</sup> Institute of Physical-Organic Chemistry and Coal Chemistry, 02160 Kyiv, Ukraine

<sup>4</sup> Institute of Photonics, University of Strathclyde, Glasgow G4 0NW, UK

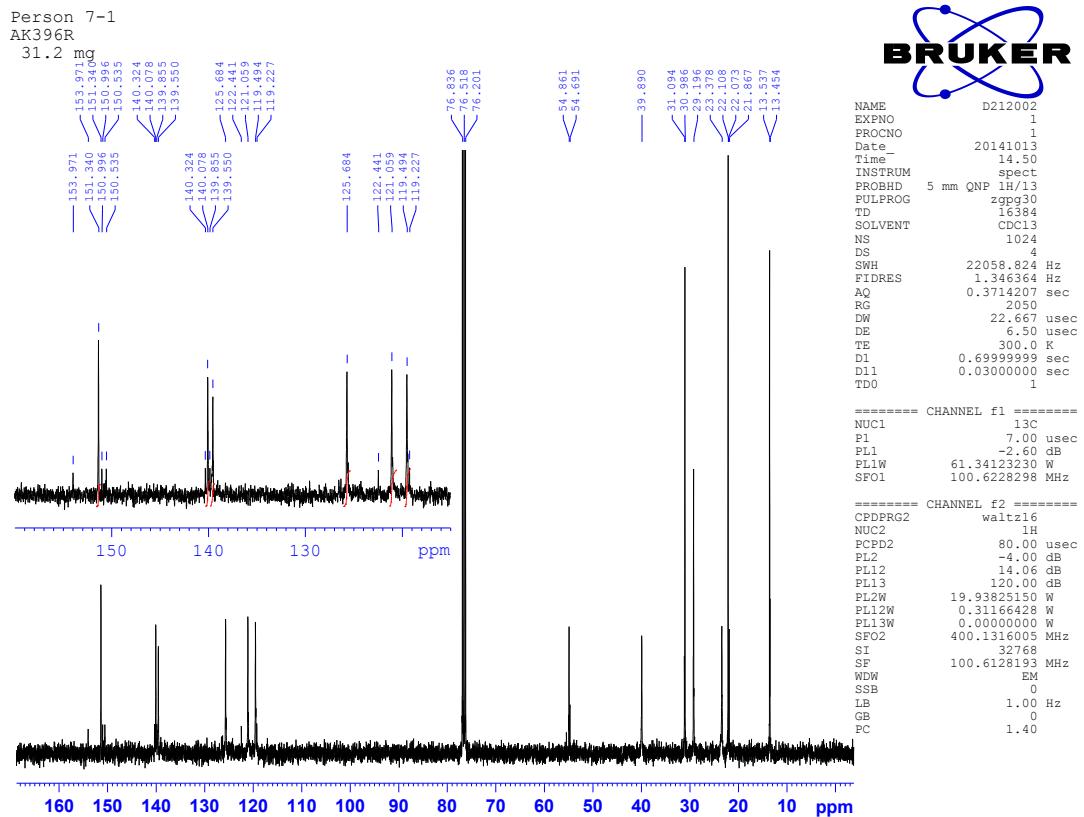
<sup>5</sup> Luminous! Center of Excellence for Semiconductor Lighting and Displays, School of Electrical and Electronic Engineering, School of Physical and Mathematical Sciences, Nanyang Technological University, Nanyang Avenue, Singapore 639798, Singapore

# These authors contributed equally to this work

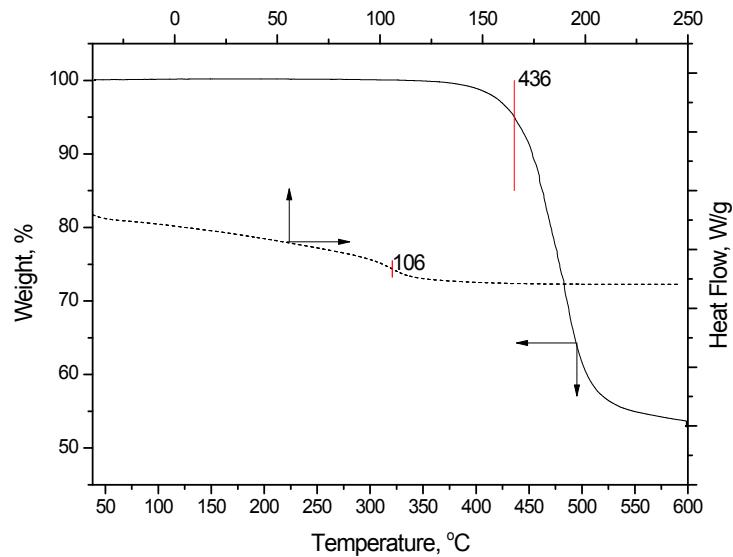
\*To whom correspondence should be addressed: [yolkan@bilkent.edu.tr](mailto:yolkan@bilkent.edu.tr), [hydemir@ntu.edu.sg](mailto:hydemir@ntu.edu.sg) (H.V.D), [peter.skabara@strath.ac.uk](mailto:peter.skabara@strath.ac.uk) (P.S)



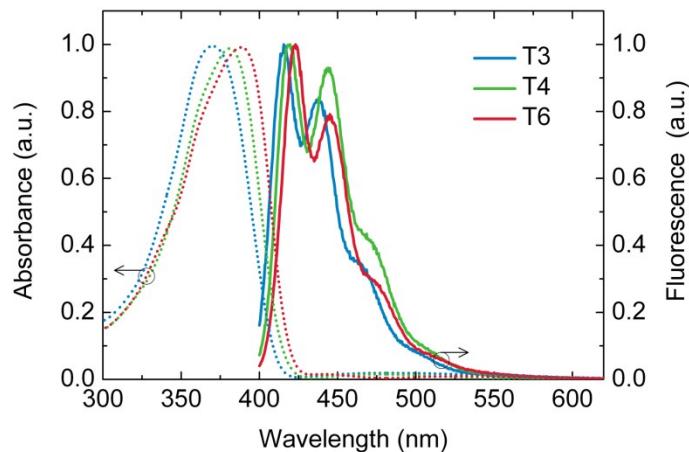
**Figure S1.**  $^1\text{H}$  NMR of T6



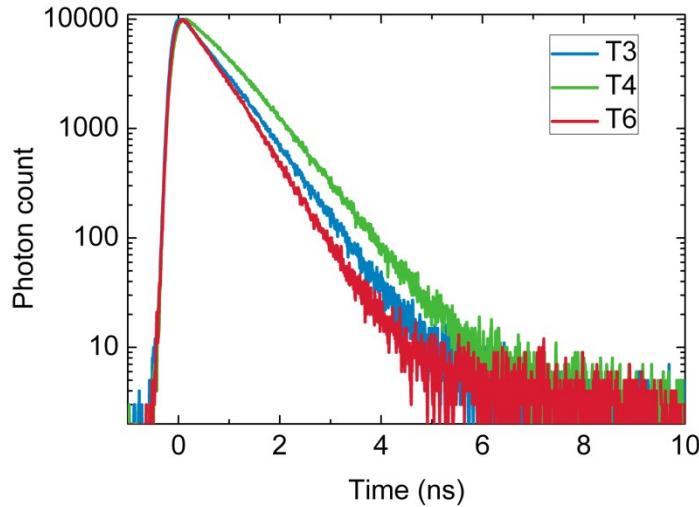
**Figure S2.**  $^{13}\text{C}$  NMR of T6



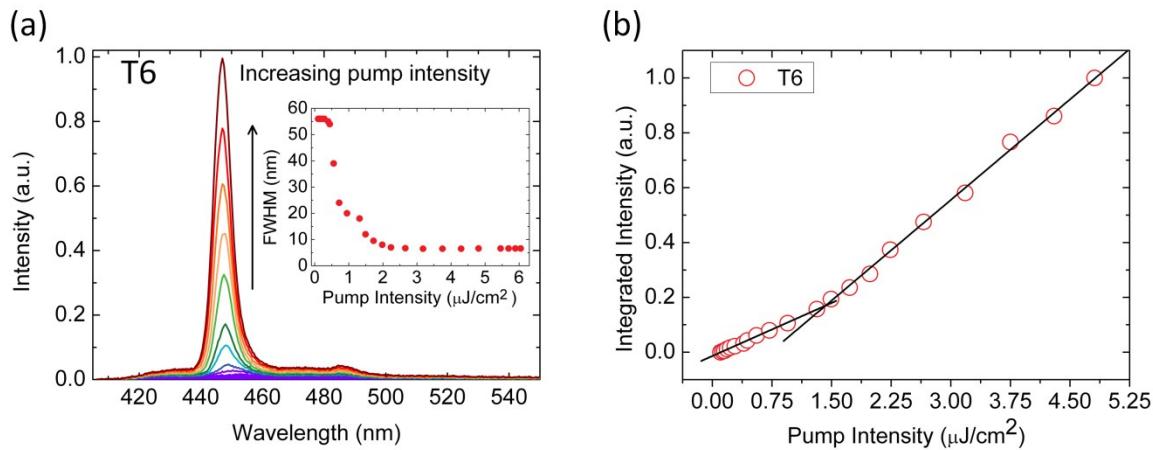
**Figure S3.** Thermogravimetric (solid line) and DSC (dashed line) analyses of T6 measured at  $10\text{ }^{\circ}\text{C}/\text{min}$ . The temperature corresponding to 5% mass loss and the glass transition are shown.



**Figure S4.** PL and absorbance spectra of T3, T4 and T6 molecules in their solid-films.



**Figure S5.** PL decay curves of the T3, T4 and T6 measured at the 0-0 transition peak with 1/e lifetimes of 0.85, 1.14 and 0.78 ns, respectively.



**Figure S6.** (a) Emission spectra on quartz of the T6 molecules as the pump intensity is increased. 1PA pumped ASE in T6 is clearly visible with an emerging narrow peak at 448 nm. The inset shows the change of the FWHM emission as a function of the pump intensity. (b) Pump intensity vs integrated emission intensity measurement under 1PA pumping in T6 molecules giving 1.43  $\mu\text{J}/\text{cm}^2$  threshold.

We have measured the extinction coefficients of the truxene oligomers at their peak absorption wavelengths as follows:

$$\epsilon = 411000 \text{ l mol}^{-1} \text{ cm}^{-1} \text{ for T3 (Ref. 1)}$$

$$\epsilon = 473000 \text{ l mol}^{-1} \text{ cm}^{-1} \text{ for T4 (Ref. 1)}$$

$$\epsilon = 680000 \text{ l mol}^{-1} \text{ cm}^{-1} \text{ for T6}$$

For this, we used T3, T4 and T6 solutions (in toluene) at  $3.76 \cdot 10^{-6}$ ,  $6.52 \cdot 10^{-7}$  and  $2.63 \cdot 10^{-6}$  mol/L concentrations, respectively.

**Table S1.** Comparison of the experimental conditions for the frequency up-converted laser thresholds in the organic semiconductors.

Reference	Material	Threshold	Pulse duration	Repetition rate	Excitation geometry	Spot size	Medium	Threshold
<b>This work</b>	Truxene based star-shaped oligofluorenes with 6 fluorene units per arm (T6)	<b>3.1 mJ/cm<sup>2</sup></b>	<b>120 fs</b>	<b>1 kHz</b>	<b>spot</b>	<b>1.48 mm</b>	<b>1 bar (ambient)</b>	<b>3.1 mJ/cm<sup>2</sup></b>
Ref. <sup>2</sup>	Ladder-type poly(p-phenylene) (MeLPPP)	>200 mJ/cm <sup>2</sup>	150 fs	1 kHz	spot	NA	10 <sup>-4</sup> mbar	>200 mJ/cm <sup>2</sup>
Ref. <sup>3</sup>	Polyfluorene (PFO)	42 mJ/cm <sup>2</sup>	100 fs	NA	NA	NA	NA	42 mJ/cm <sup>2</sup>
Ref. <sup>4</sup>	Bisfluorene dendrimer (BPCz)	4.9 mJ/cm <sup>2</sup>	100 fs	5 kHz	spot	85 μm	10 <sup>-4</sup> mbar	4.9 mJ/cm <sup>2</sup>
Ref. <sup>5</sup>	1,4-bis[2-[4-[N,N-di(p-totyl)amino]phenyl]vinyl]benzene (DADSB)	4.5 mJ/cm <sup>2</sup>	150 fs	1 kHz	spot	1 mm	1 bar (ambient)	4.5 mJ/cm <sup>2</sup>

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